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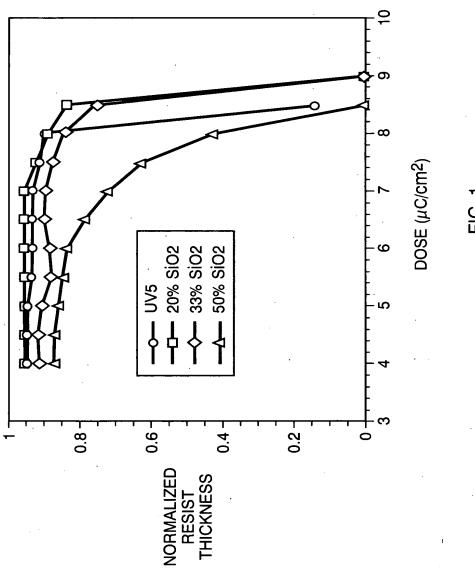


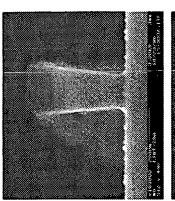
FIG. 1

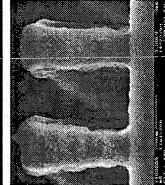
EXPERIMENTAL 20% SiO₂ EIRT RESIST

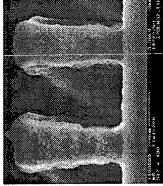
UV5 RESIST COMMERCIAL ORGANIC RESIST







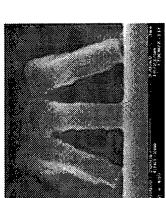


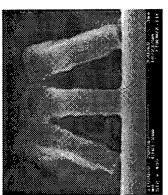


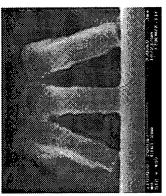
300 nm

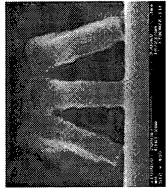
200 nm

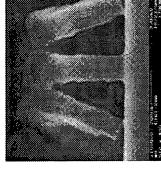
300 nm

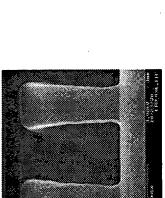


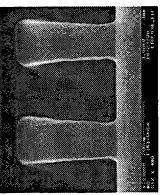


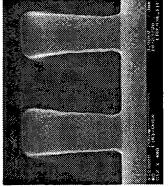












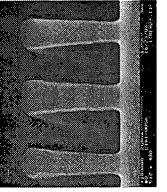
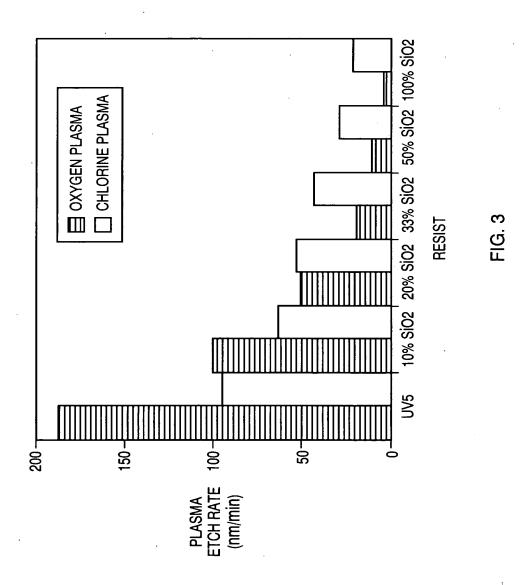




FIG. 2





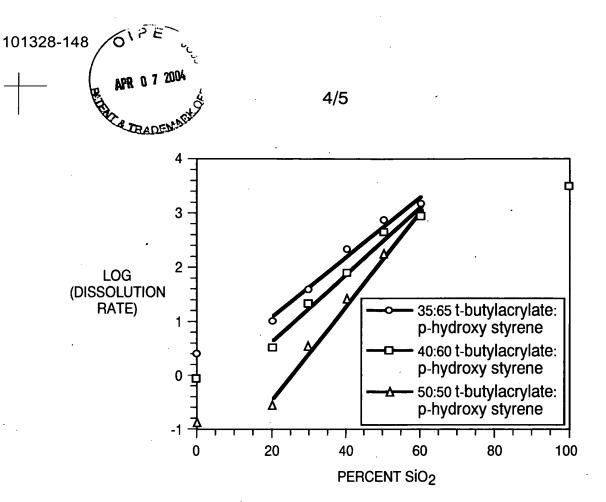


FIG. 4

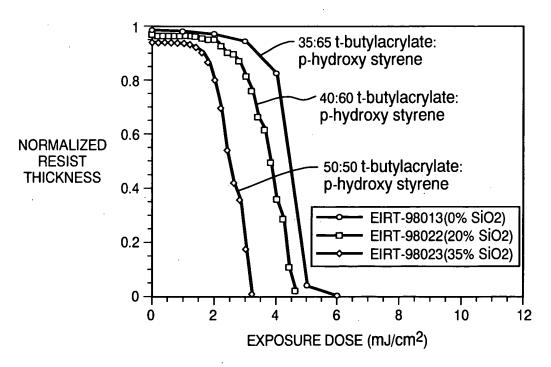


FIG. 5



